

Abdullah H Alshehri

List of Publications by Year in descending order

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#	ARTICLE	IF	CITATIONS
1	Nanoscale Film Thickness Gradients Printed in Open Air by Spatially Varying Chemical Vapor Deposition. <i>Advanced Functional Materials</i> , 2021, 31, 2103271.	14.9	8
2	Metal-Insulator-Insulator-Metal Diodes with Responsivities Greater Than 30 A W^{-1} Based on Nitrogen-Doped TiO_x and AlO_x Insulator Layers. <i>Advanced Electronic Materials</i> , 2021, 7, 2100467.	5.1	7
3	Metal-Insulator-Metal Diodes: Quantum-Tunneling Metal-Insulator-Metal Diodes Made by Rapid Atmospheric Pressure Chemical Vapor Deposition (<i>Adv. Funct. Mater.</i> 7/2019). <i>Advanced Functional Materials</i> , 2019, 29, 1970042.	14.9	1
4	Near zero-bias MIIM diode based on TiO_2/ZnO for energy harvesting applications. <i>AIP Advances</i> , 2019, 9, .	1.3	18
5	Quantum-Tunneling Metal-Insulator-Metal Diodes Made by Rapid Atmospheric Pressure Chemical Vapor Deposition. <i>Advanced Functional Materials</i> , 2019, 29, 1805533.	14.9	39
6	Simple plasma assisted atomic layer deposition technique for high substitutional nitrogen doping of TiO_2 . <i>Journal of Vacuum Science and Technology A: Vacuum, Surfaces and Films</i> , 2018, 36, 031602.	2.1	5